FORM PTO-1449 (Equivalent) U.S. Department of Commerce Patent and Trademark Office

U.S. Application Serial No. 10/724.454

Atty. Docket No.
AM-8472

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INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Use several sheets if necessary)

Sang H. Ahn et al. Applicants

November 28, 2003 Filing Date

<u>Unknown</u> Group

U. S. PATENT DOCUMENTS							
Examiner Initial	Document Number	Issue <u>Date</u>	Name	Class	Subclass	Filing Date  If Appropriate	
no	6,171,764	01/09/01	Ku et al.	430	322		
mp	6,227,141	05/08/01	Sharan et al.	118	723 E		
MD	6,607,984	08/19/03	Lee et al.	438	700		

U. S. PATENT APPLICATION DOCUMENTS								
Examiner Initial	Document Number	Publication Date	Name	Class	Subclass	Filing Date		
bo	2003/0087518 A1	05/08/03	Chen et al.	438	637	11/08/01		

Examiner

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05/24/05

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FOREIGN PATENT DOCUMENTS

Examiner Initial	Document Number	Publication Date	<u>Name</u>	Class	Subclass	Translation If Appropriate
no	EP 1011135	06/21/00	Hsia et al.	H01L	21/768	
DUD	WO 01/09683	02/08/01	Lee et al.	G03F	7/09	

## OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)



J. E. Klemberg-Sapieha et al., "Dual Microwave-R.F. Plasma Deposition of Functional Coatings", Thin Solid Films, Vol. 193/194, pp. 965-972 (1990).

pro

A. Raveh et al., "Deposition and properties of diamondlike carbon films produced in microwave and radio-frequency plasma", J. Vac. Sci. Technol. A, Vol. 10, No. 4, pp. 1723-1727 (1992).

Examiner

Date Considered

05/24/05

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